

Thickness, Temperature and Magnetic Field Dependent Resistance of Cu_{1.8}S

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Extended Abstract

Copper sulphides (Cu_xS, 1 ≤ x ≤ 2) exhibit an extensive range of optical and electrical properties as many as their meta-stable phases and structures [1-4]. Stoichiometric ratio of Cu and S can be tuned by changing synthesis conditions. Most copper rich Cu_xS compounds are known as semiconductors with a 1.2 ~ 2 eV direct/indirect band gap. Although lots of practical studies have been made for energy storage [5] and photovoltaic device applications [6], their electrical properties at low temperatures in the presence of magnetic fields are rarely reported so far. Here, we report electron transport properties of Cu_{1.8}S thin films varying temperature and magnetic fields. Furthermore, we demonstrate surface effects as the thickness varies.

Cu thin films with different thicknesses are deposited on c-plane sapphire substrates (0001) by using RF magnetron sputtering. The purity of the used Cu target is 5 N, and base and working pressures are ~ 10⁻⁷ and 10⁻² torr, respectively. The pristine sputtered Cu films are exposed to H₂S at room temperature and annealed at 250 °C. The thickness of the films is measured by atomic force microscopy (AFM) and found to be ~ 5, 15, 30, and 50 nm. The Cu_{1.8}S phase is confirmed by grazing incidence X-ray diffraction (GIXRD) with less than 1 degree incidence angle. Collinear 4-point measurements are performed between 7 K and room temperature, in order to investigate their electrical properties. Magnetic fields up to 1 Tesla are applied and magnetic properties are investigated at various temperatures. Intriguing phenomena such as metal insulator transition (MIT) and magnetic phase transition are observed as the thickness varies.

References

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